## Serial No. Not Yet Assigned Atty. Doc. No. 2002P08684WOUS

## Amendments To The Claims:

Please amend the claims as shown.

## 1-9 (canceled)

10. (new) A method for the electrolytic deposition of an alloy at least two constituents as a layer on a substrate, comprising:

arranging the alloy in an electrolyte and the at least two constituents of the alloy are suspended and/or dissolved;

using a plurality of repeated voltage pulses for the electrolytic deposition and combined in a sequence that comprises at least two different blocks;

adapting one block in each case to a constituent of the alloy to achieve optimum deposition of the constituent and a block comprising two or more voltage pulses, and

following a first block of a sequence by a second block in the same sequence of the same polarity and the second block has a higher or lower voltage level on account of being adapted to one constituent of the alloy.

- 11. (new) The method as claimed in claim 10, wherein mechanical vibrations are imparted to the electrolyte.
- 12. (new) The method as claimed in claim 11, wherein an ultrasound probe is operated in the electrolyte.
- 13. (new) The method as claimed in claim 10, wherein a current/voltage pulse is used for the electrolytic deposition and is defined by the current/voltage pulse time profile.
- 14. (new) The method as claimed in claim 13, wherein a current/voltage pulse time profile is a square-wave or a delta-wave form.
- 15. (new) The method as claimed in claim 10, wherein both a positive and a negative current/voltage pulses are used for the electrolytic deposition.

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- 16. (new) The method as claimed in claim 10, wherein a block is defined by a number of current pulses, pulse duration, interpulse period, current intensity, and time profile.
- 17. (new) The method as claimed in claim 10, wherein an MCrAlY layer is deposited as an alloy on a substrate, with M being an element selected from the group consisting of iron, cobalt and nickel.
- 18. (new) The method as claimed in claim 10, wherein a gradient in the composition of the material is produced in an alloy layer.
- 19. (new) The method as claimed in claim 10, wherein a base current is superimposed on the current pulses and the interpulse periods.
- 20. (new) The method as claimed in claim 10, wherein a base current is superimposed on the current pulses or the interpulse periods.